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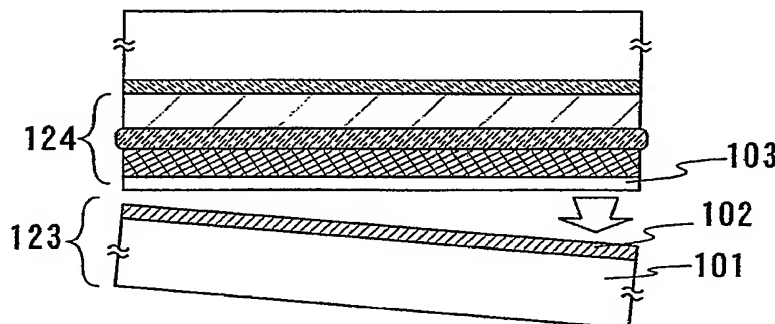
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(54) Title: METHOD OF MANUFACTURING OPTICAL FILM



(57) Abstract: To provide a method of
manufacturing an optical film formed
on a plastic substrate. There is provided
a method of manufacturing an optical
film including the steps of laminating
a separation layer and an optical filter
on a first substrate, separating the
optical filter from the first substrate,
attaching the optical filter to a second
substrate. Since the optical film
manufactured according to the invention
has flexibility, it can be provided on
a portion or a display device having a
curved surface. Further, the optical film

is not processed at high temperatures, and hence, an optical film having high yield with high reliability can be formed. Furthermore,
an optical film having an excellent impact resistance property can be formed.

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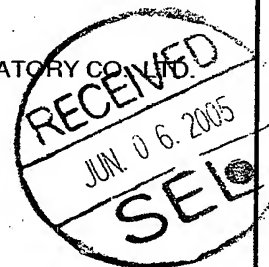
From the INTERNATIONAL BUREAU

FIRST NOTICE INFORMING THE APPLICANT OF
THE COMMUNICATION OF THE INTERNATIONAL
APPLICATION (TO DESIGNATED OFFICES WHICH
DO NOT APPLY THE 30 MONTH TIME LIMIT
UNDER ARTICLE 22(1))

(PCT Rule 47.1(c))

To:

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Date of mailing (day/month/year) 02 June 2005 (02.06.2005)		
Applicant's or agent's file reference 00000PCT7433		IMPORTANT NOTICE
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Applicant SEMICONDUCTOR ENERGY LABORATORY CO., LTD. et al		

- ATTENTION:** For any designated Office(s), for which the time limit under Article 22(1), as in force from 1 April 2002 (30 months from the priority date), **does apply**, please see Form PCT/IB/308(Second and Supplementary Notice) (to be issued promptly after the expiration of 28 months from the priority date).
- Notice is hereby given that the following designated Office(s), for which the time limit under Article 22(1), as in force from 1 April 2002, **does not apply**, has/have requested that the communication of the international application, as provided for in Article 20, be effected under Rule 93bis.1. The International Bureau has effected that communication on the date indicated below:
06 May 2005 (06.05.2005)

CH

In accordance with Rule 47.1(c-bis)(i), those Offices will accept the present notice as conclusive evidence that the communication of the international application has duly taken place on the date of mailing indicated above and no copy of the international application is required to be furnished by the applicant to the designated Office(s).

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4. TIME LIMITS for entry into the national phase

For the designated Office(s) listed above, and unless a demand for international preliminary examination has been filed before the expiration of **19 months** from the priority date (see Article 39(1)), the applicable time limit for entering the national phase will, **subject to what is said in the following paragraph**, be **20 MONTHS** from the priority date.

In practice, **time limits other than the 20-month time limit** will continue to apply, for various periods of time, in respect of certain of the designated Offices listed above. For **regular updates on the applicable time limits** (20 or 21 months, or other time limit), Office by Office, refer to the *PCT Gazette*, the *PCT Newsletter* and the *PCT Applicant's Guide*, Volume II, National Chapters, all available from WIPO's Internet site, at <http://www.wipo.int/pct/en/index.html>.

It is the applicant's **sole responsibility** to monitor all these time limits.



The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland	Authorized officer Masashi Honda
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